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(54) Title: COMPOSITION AND PROCESS FOR WET STRIPPING REMOVAL OF SACRIFICIAL ANTI-REFLECTIVE MATERIAL

(57) Abstract: A composition and process for wet stripping removal of sacrificial anti-reflective silicate material, e.g., from a substrate or article having such material deposited thereon, particularly where the sacrificial anti-reflective material is present with permanent silicate materials desired to be unaffected by the wet stripping composition.